

Controls of Electronic Assemblies

▲ Main tasks

- Physical analysis of electronic devices
- Evaluation and qualification of manufacturing assembly processes (IPC A 610)
- Failure analysis
- > Technical Cleanliness: product evaluation, manufacturing monitoring
- Precision measurement
- Samples exposure to chemical fluids

1400 analysis/year, a team of 20 employees specialized in different analytical techniques: visual inspection of electronic assemblies, metallographic analysis, chemical & physical analysis, material characterization.

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Non-Destructive analysis





> X-RAY EQUIPEMENTS

Including 3D computed tomography systems: General Electric "phoenix vI tomelxs"

X-YLON Cheetah device



Physical Analysis



> FTIR EQUIPEMENTS (PERKIN ELMER FRONTIER SPOTLIGHT 400)

Analysis of organic materials



> ELECTRONIC MICROSCOPY LAB SEM (JEOL-6480LV) SEM FEK (JEOL-7200F)

Magnification up to 200k Imaging & chemical analysis





Controls of PCB & Component Finishing



WETTING BALANCE (MUST SYSTEM III) Solderability test



> FLUORESCENCE X (FISHERSCOPE XVDM)



> SERA Pure Tin plating thickness evaluation



> DROP STAGE ANALYSIS SURFACE (KRÜS)



Precision Dimensional Measurements



CMM DEA GLOBAL ADVANTAGE



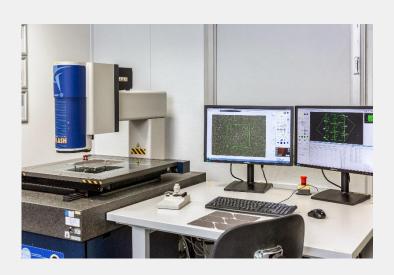
> CMM ZEISS CONTURA



> LINE SCAN 3D



> ROUGHNESS EVALUATION ALTISURF 520



> 2D MEASUREMENT OGP SMARTSCOPE FLASH 300 (AND 400)



Polymers analysis



DYNAMIC MECHANICAL ANALYSIS



> THERMO MECHANICAL ANALYSIS (METTLER TMA40)



- > THERMOGRAVIMETRY (METTLER TG50)
- > GAZ CHROMATOGRAPHY AND MASS SPECTROMETER



DIFFERENTIAL SCANNING CALORIMETRY (METTLER DSC30)



Controls of Electronics Assembly



 OPTICAL EQUIPMENTS WITH MAGNIFICATION UP TO 100X
 Equipment for metallographic analysis





DIGITAL MICROSCOPE DSX110
 Whiskers inspection, precision measurement



Metallographic analysis



- > SAW DEVICES
- Disc saws
- Wire saws



> IONIC POLISHING SYSTEMS (JEOL)

> MECHANIC GRINDING & POLISHING



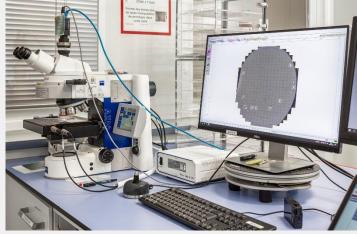




Technical Cleanliness analysis



- > DETERMINING COMPONENTS AND PRODUCT CLEANLINESS
- > MONITORING THE SEDIMENTATION BEHAVIOR OF PARTICLES
- > SURVEILLANCE OF ASSEMBLY PROCESS
- > IONIC CONTAMINATION (IONOGRAPH AND IONIC CHROMATOGRAPGY







Chemical fluids resistance test



- > EXPOSURE TO CHEMICAL FLUIDS UNDER AMBIANT OR HEATED CONDITIONS
- > LARGE DIVERSITY OF CHEMICAL FLUIDS AVAILABLE
- > FLUID APPLICATION, CLEANING
- > INSPECTION OF SAMPLES





Test methods

Physical analysis	Standards used
Metallographic analysis (cross-sections)	IPC-TN-650
Evaluation of electronic components assemblies	IPC A 610 IPC A 600
Voids evaluation by X-Rays in BGA	IPC A 610
Voiding in solder joints	IEC TR 61191
SEM Analysis: Imaging & chemical analysis	
Ion Beam Polishing	
Organic material identification by FTIR	IPC TM 650 (Infrared analytical method) N°2.3.39
Dimensional measurement by optical device	ISO 14253-1 ISO 14253-2
Evaluation of mechanical/electronic assemblies by Computed Tomography	





Test methods

Chemical analysis	Standards used
Ionic contamination evaluation	IPC TM 650 2.3.25-D IPC TM 650 2.3.25-1 TST N002 16 05 030
Micro etching metal & alloys	ASTM E 407 – 07
Exposure to chemical fluids	
Selective electro-chemical analysis	(CQR) for Printed Circuit Boards
Rubber de-formulation	
Rubber swelling characterization	
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Cleanliness analysis	Standards used
	Standards used ISO 16232 Accreditation ISO17025
Cleanliness analysis	ISO 16232
Cleanliness analysis Cleanliness analysis	ISO 16232 Accreditation ISO17025
Cleanliness analysis Cleanliness analysis Wetting tests	ISO 16232 Accreditation ISO17025 Standards used A2C00052907AAA
Cleanliness analysis Cleanliness analysis Wetting tests Evaluation of components solderability	ISO 16232 Accreditation ISO17025 Standards used A2C00052907AAA J STD 002 IPC A 600, J STD 003,

spectrometry method





Test methods

Accurate Measurements	Standards used
3D Measurements with Coordinate Measuring Machine (CMM)	ISO 14253-1/2/3, ISO 1101
1D/2D Accurate Measurements	ISO 14253-1/2/3, ISO 1101
Geometry measurement by Computed Tomography (CT)	VDI / VDE 2627, ISO 1101
Surface roughness evaluation	ISO 21920

Polymers characterization	Standards used
Assignment of Glass Transition Temperature & Thermodynamic measurements by Differential Scanning Calorimetry (DSC)	IPC TM 650 2.4.25 ISO 11357-2 ISO-11357-3
Polymer characterization by Dynamic Mechanical Analysis (DMA)	ASTM E1640
Polymer characterization by Thermo Gravimetric Analysis (TGA)	ASTM E 1131 ISO 11358-1 ISO 9924-2 ISO 9924-3
Determination of liquid effects on vulcanized rubbers	ISO 1817



Test methods

Polymers characterization	Standards used
Test method for compositional analysis using gas chromatography and mass spectrometer	
Bare Printed Board Cleanliness by Ion Chromatography	IPC TM 650 2.3.28.2
Halide content of soldering fluxes and pastes	IPC TM 650 2.3.28.1
Ionic Analysis of Circuit Boards, Ion Chromatography Method	IPC TM 650 2.3.28

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